	Application No.	Applicant(s)		
	09/753,616	ASADA ET AL	ASADA ET AL.	
Notice of Allowability	Examiner	Art Unit		
	Samuel A Gebremariam	2811	لهم ا	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in to or other appropriate communi GHTS. This application is sub-	nis application. If not includication will be mailed in due	ded e course. <b>THIS</b>	
1. $\boxtimes$ This communication is responsive to $3/7/03$ .				
2. 🔀 The allowed claim(s) is/are <u>2-6,14 and 15</u> .				
3.   The drawings filed on 04 January 2001 are accepted by the	e Examiner.			
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority una)  All b)  Some* c)  None of the:  1.  Certified copies of the priority documents have  2.  Certified copies of the priority documents have  3.  Copies of the certified copies of the priority documents have  International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li> <li>5.  A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give  1.  CORRECTED DRAWINGS (as "replacement sheets") must  (a)  including changes required by the Notice of Draftspers  1.  hereto or 2.  To Paper No./Mail Date  (b)  including changes required by the attached Examiner's  Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in to  1.  DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT</li> </ul>	been received. been received in Application cuments have been received in Application of this communication to file a IENT of this application.  itted. Note the attached EXAN as reason(s) why the oath or do to be submitted.  son's Patent Drawing Review (communication).  Amendment / Comment or in the header according to 37 CFR sit of BIOLOGICAL MATER	No In this national stage application this national stage application this national stage application to the complying with the result.  INER'S AMENDMENT or lectoration is deficient.  PTO-948) attached in the Office action of drawings in the front (not the 1.121(d).  RIAL must be submitted.	equirements  NOTICE OF	
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sun Paper No./M 7. ☑ Examiner's A 8. ☑ Examiner's S 9. ☐ Other		lowance	

Application/Control Number: 09/753,616 Page 2

Art Unit: 2811

### **DETAILED ACTION**

# Election/Restrictions

1. This application is in condition for allowance except for the presence of claims 7 to 13 non-elected without traverse. Accordingly, claims 7-13 have been cancelled.

#### Allowance

2. Claims 2-6 and 14 and 15 are allowed.

# Reason for allowance

The following is an examiner's statement of reasons for allowance: The prior art 3. of record does not teach or suggest, singularly or in combination at least the limitation "first MOS transistor having an impurity region as drain connected to said impurity region of said photodiode, a second MOS transistor having an impurity region as source connected to a source of said first MOS transistor and a third MOS transistor formed on said substrate, the third transistor having an impurity region as a source connected to drain of the second MOS transistor and a silicide film is formed on each surface of the sources and drains of the first, second and third MOS transistor except for the drain of the first MOS transistor" is the first major difference between the prior art and the claimed invention and the second major difference is "a silicon oxide film is formed on a surface of the impurity region of the photodiode and the drain region of the first MOS transistor which connects to the impurity region of the photodiode, but a silicide film is formed on a surface of the source region of the first MOS transistor which is also the drain region of the second MOS transistor and on a surface of the drain region of the second MOS transistor".

Application/Control Number: 09/753,616

Art Unit: 2811

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Samuel A Gebremariam whose telephone number is (571)-272-1653. The examiner can normally be reached on 8:00am-4:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on (571) 272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SAG

August 19, 2004

CODIF LEE

Page 3

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800